Synthesis and Characterization of Sterically Hindered Alkylaluminum-Phosphorus and -Arsenic Compounds. X-ray Crystal Structures of $(Me_3ECH_2)_3Al \cdot E'(SiMe_3)_3$ (E = Si, E' = As; E = C, E' = P, As), (Me₃SiCH₂)₂(Br)Al·P(SiMe₃)₃, and $[(Me_3SiCH_2)(X)AlE(SiMe_3)_2]_2$ (X = Br, E = P, As; X = Me_3SiCH_2 , E = As)

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Received February 13, 1998

Reaction of $(Me_3SiCH_2)_3Al$ with $E(SiMe_3)_3$ (E = P, As) in a 1:1 mole ratio affords the Lewis acid-base adducts (Me₃SiCH₂)₃Al·P(SiMe₃)₃ (1) and (Me₃SiCH₂)₃Al·As(SiMe₃)₃ (2). Similarly, the 1:1 mole ratio reaction of $(Me_3CCH_2)_3Al$ with $E(SiMe_3)_3$ (E = P, As) leads to the isolation of (Me₃CCH₂)₃Al·P(SiMe₃)₃ (**3**) and (Me₃CCH₂)₃Al·As(SiMe₃)₃ (**4**). The adduct (Me₃SiCH₂)₂- $(Br)Al \cdot P(SiMe_3)_3$ (5) was obtained from the 1:1 mole ratio reaction of $(Me_3SiCH_2)_2AlBr$ with $P(SiMe_3)_3$. The dimers $[(Me_3SiCH_2)(Br)AlP(SiMe_3)_2]_2$ (6) and $[(Me_3SiCH_2)(Br)AlAs(SiMe_3)_2]_2$ (7) were isolated as products of the lithium halide elimination reactions of (Me₃SiCH₂)AlBr₂ (10) with $LiE(SiMe_3)_2$ (E = P, As), while reaction of $(Me_3SiCH_2)_2AIBr$ with these same lithium pnictide salts leads to the isolation of $[(Me_3SiCH_2)_2AIP(SiMe_3)_2]_2$ (8) and $[(Me_3SiCH_2)_2AIAs (SiMe_3)_2]_2$ (9). Various physical and spectroscopic data, including a variable-temperature NMR study of the dimeric compounds 6-9, are presented for the above compounds, as are the single-crystal X-ray structures of 2-7 and 9.

Introduction

The bulk of research in our laboratory over the past decade has focused on the synthesis and characterization of potential single-source precursor compounds to group 13–group 15 materials, obtained predominately through dehalosilylation and lithium halide elimination reactions. In an attempt to prepare compounds which may serve as precursors to aluminum phosphides and arsenides, we have become interested in the synthesis of novel compounds containing this 13-15 linkage. For example, we have recently reported the isolation of the Lewis acid-base adducts $X_3Al \cdot E(SiMe_3)_3$ (X = Cl and Br, E = P¹ X = Cl, $E = As^2$ and $Ph_3Al \cdot E(SiMe_3)_3$ (E =P and As³), as well as the ring-compounds $[Et_2AlE$ - $(SiMe_3)_2]_2$ (E = P⁴ and As⁵). In the present study, we undertook the synthesis of a series of aluminum compounds containing the bulkier (trimethylsilyl)methyl and neopentyl ligands. While these starting materials have been known for some time, relatively little chemistry has been performed with them, especially in the area of 13–15 precursor compounds. A comparison of these results with a similar series of reactions involving the heavier metals gallium and indium⁶ would be of interest. Additionally, we wished to probe the feasibility of trimethylsilyl bromide elimination in the synthesis of aluminum-phosphorus and -arsenic compounds.

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Experimental Section

General Considerations. All manipulations of air- and moisture-sensitive materials were performed in a Vacuum Atmospheres HE-493 Dri-Lab containing an argon atmosphere or by standard Schlenk techniques. Pentane, hexane, toluene, and THF were distilled over sodium/potassium alloy under dry dinitrogen. (Me₃SiCH₂)₃Al,⁷ (Me₃SiCH₂)₂AlBr,⁸ (Me₃CCH₂)₃-Al,⁹ P(SiMe₃)₃,¹⁰ and As(SiMe₃)₃¹¹ were prepared from literature procedures. LiP(SiMe₃)₂¹² and LiAs(SiMe₃)₂¹¹ were prepared from the 1:1 reaction of P(SiMe₃)₃ or As(SiMe₃)₃ with LiCH₃ in THF. AlBr₃ was purchased from Strem Chemicals, Inc., and purified through sublimation. The integrity of all starting materials was confirmed using ¹H NMR spectroscopy. ¹H, ¹³C{¹H}, and ³¹P{¹H} NMR spectra were recorded on a Varian Unity XL-400 spectrometer operating at 400, 100.6, and 161.9 MHz, respectively. 1H and 13C{1H} spectra were referenced to TMS using the residual protons or carbons of deuterated benzene at δ 7.15 or 128.0, respectively. ³¹P{¹H} spectra were referenced externally to 80% H₃PO₄ at δ 0.00. All NMR samples were prepared in 5-mm tubes which were septum-sealed under argon or flame-sealed under vacuum (in the case of the variable-temperature experiments). Melting points (uncorrected) were obtained with a Thomas-Hoover Unimelt apparatus, using capillaries that were flame-sealed under argon. Elemental analyses were performed by E+R Microanalytical Laboratory, Inc., Corona, NY.

Preparation of (Me₃SiCH₂)₃Al·P(SiMe₃)₃ (1). (Me₃- $SiCH_2$, Al (0.288 g; 1.00 mmol) was added with 20 mL of hexane to a 250 mL flask equipped with a stir bar and Teflon valve. P(SiMe₃)₃ (0.250 g; 1.00 mmol) in 30 mL of hexane was added slowly via pipet, and the clear colorless solution was stirred for 6 h at room temperature. The volatiles were removed in vacuo, yielding a white solid which was extracted with warm pentane and allowed to evaporate at -30 °C, producing colorless crystals of 1 (0.468 g, 86% yield). Mp: 95-99 °C. Anal. Calcd (found) for C21H60AlPSi6: C, 46.78 (46.46); H, 11.22 (11.41). ¹H NMR: δ -0.46 (s, 6H, Me₃Si*CH*₂-), δ 0.27 [d, 27H, $-\text{SiMe}_3 (J_{P-H} = 4.4 \text{ Hz})$], δ 0.31 (s, 27H, Me_3 SiCH₂-). ¹³C{¹H} NMR: δ 3.33 (s, Me₃Si*CH*₂-), δ 3.45 (s, *Me*₃-SiCH₂-), δ 3.66 [d, -SiMe₃ ($J_{P-C} = 9.1$ Hz)]. ³¹P{¹H} NMR: $\delta - 240.86$ (s).

Preparation of (Me₃SiCH₂)₃Al·As(SiMe₃)₃ (2). The procedure used was identical to that described for 1, with (Me₃-SiCH₂)₃Al (0.288 g; 1.00 mmol) and As(SiMe₃)₃ (0.294 g; 1.00 mmol). (Me₃SiCH₂)₃Al·As(SiMe₃)₃ (2) was isolated (0.554 g, 95% yield). Mp: 89-95 °C. Anal. Calcd (found) for C₂₁H₆₀-AlAsSi₆: C, 43.25 (42.88); H, 10.37 (10.11). ¹H NMR: δ -0.42 (s, 6H, Me₃Si*CH*₂-), δ 0.29 (s, 27H, *Me*₃SiCH₂-), δ 0.32 (s, 27H, -SiMe₃). ¹³C{¹H} NMR: δ 3.37 (s, Me₃SiCH₂-), δ 3.97 (s, -SiMe₃).

Preparation of (Me₃CCH₂)₃Al·P(SiMe₃)₃ (3). (Me₃CCH₂)₃-Al (0.240 g; 1.00 mmol) was added with 20 mL of hexane to a 250 mL flask equipped with a stir bar and Teflon valve. P-(SiMe₃)₃ (0.250 g; 1.00 mmol) in 30 mL of hexane was added slowly via pipet, and the clear colorless solution was stirred for 12 h at room temperature. The solvent level was reduced in vacuo and allowed to evaporate at -30 °C, producing colorless crystals of 3 (0.431 g, 88% yield). Mp: 115-117 °C. Anal. Calcd (found) for C24H60AlPSi3: C, 58.72 (58.63); H, 12.32 (12.16). ¹H NMR: δ 0.31 [d, 27H, -SiMe₃ ($J_{P-H} = 4.4$

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Hz)], δ 0.66 (s, 6H, Me₃CCH₂-), δ 1.28 (s, 27H, Me₃CCH₂-). ¹³C{¹H} NMR: δ 32.64 (s, Me₃C*CH*₂-), δ 35.51 (s, *Me*₃CC-H₂-), δ 3.82 [d, -SiMe₃ ($J_{P-C} = 9.1$ Hz)]. ³¹P{¹H} NMR: δ -241.34 (s).

Preparation of (Me₃CCH₂)₃Al·As(SiMe₃)₃ (4). The procedure used was identical to that described for 3, with (Me₃-CCH₂)₃Al (0.240 g; 1.00 mmol) and As(SiMe₃)₃ (0.294 g; 1.00 mmol). (Me₃CCH₂)₃Al·As(SiMe₃)₃ (4) was isolated (0.422 g, 79% yield). Mp: 114-117 °C. Anal. Calcd (found) for C₂₄H₆₀-AlAsSi₃: C, 53.89 (53.66); H, 11.31 (11.27). ¹H NMR: δ 0.34 (d, 27H, -SiMe₃), δ 0.64 (s, 6H, Me₃C*CH*₂-), δ 1.20 (s, 27H, Me_3CCH_2 -). ¹³C{¹H} NMR: δ 4.15 (s, -SiMe₃), δ 32.19 (s, Me₃C*CH*₂-), δ 35.33 (s, *Me*₃CCH₂-).

Preparation of (Me₃SiCH₂)₂(Br)Al·P(SiMe₃)₃ (5). The procedure used was identical to that described for 3, with (Me₃-SiCH₂)₂AlBr (0.281 g; 1.00 mmol) and P(SiMe₃)₃ (0.250 g; 1.00 mmol). (Me₃SiCH₂)₂(Br)Al·P(SiMe₃)₃ (5) was isolated (0.301 g, 57% yield). Mp: 94-100 °C. Anal. Calcd (found) for C17-H₄₉AlPBrSi₅: C, 38.39 (38.47); H, 9.29 (9.26). ¹H NMR: δ -0.45 (s, 4H, Me₃Si*CH*₂-), δ 0.28 [d, 27H, -SiMe₃ ($J_{P-H} =$ 4.8 Hz)], δ 0.31 (s, 18H, Me₃SiCH₂-). ¹³C{¹H} NMR: δ 3.33 (s, Me₃Si*CH*₂--), δ 3.44 (s, *Me*₃SiCH₂--), δ 3.65 [d, -SiMe₃ (*J*_{P-C} = 10.3 Hz)]. ³¹P{¹H} NMR: δ -225.28 (s).

Preparation of [(Me₃SiCH₂)(Br)AlP(SiMe₃)₂]₂ (6). (Me₃-SiCH₂)AlBr₂ (0.411 g; 1.50 mmol) was added with 20 mL of hexane to a 250 mL flask equipped with a stir bar and Teflon valve. To this stirred room-temperature solution was added LiP(SiMe₃)₂·0.6THF (0.340 g; 1.50 mmol). Within minutes, a hazy red color developed, and stirring was continued for 12 h. At the end of this time, the LiCl was allowed to settle, and the red solution was transferred to a second flask via cannula. The solvent volume was reduced in vacuo and allowed to evaporate at -30 °C. Within 24 h, clear, colorless crystals of **6** (0.265 g, 71% yield) had formed. Mp: 187–192 °C. Anal. Calcd (found) for C₂₀H₅₈Al₂P₂Br₂Si₆: C, 32.33 (32.45); H, 7.87 (7.93). ¹H NMR: δ –0.06 (bs, 4H, Me₃Si*CH*₂–), δ 0.36 (s, 18H, *Me*₃SiCH₂-), δ 0.49 [t, 36H, -SiMe₃ (*J*_{P-H} = 2.8 Hz)]. ¹³C{¹H} NMR: δ 2.95 (s, *Me*₃SiCH₂-), δ 4.13 [t, -SiMe₃ (*J*_{P-C} = 4.9 Hz)]. ³¹P{¹H} NMR: δ -215.15 (s).

Preparation of [(Me₃SiCH₂)(Br)AlAs(SiMe₃)₂]₂ (7). The procedure used was identical to that described for 6, with (Me₃-SiCH₂)₂AlBr (0.274 g; 1.00 mmol) and LiAs(SiMe₃)₂•0.6THF (0.270 g; 1.00 mmol). [(Me₃SiCH₂)(Br)AlAs(SiMe₃)₂]₂ (7) was isolated (0.310 g, 75% yield). Mp: 189-191 °C (decomposed to an orange liquid). Anal. Calcd (found) for C₂₀H₅₈Al₂As₂-Br₂Si₆: C, 28.91 (28.73); H, 7.04 (6.72). ¹H NMR: δ -0.01 (s, 4H, Me₃Si*CH*₂-), δ 0.37 (s, 18H, Me₃SiCH₂-), δ 0.52 (s, 36H, -SiMe₃). ¹³C{¹H} NMR: δ 2.87 (s, *Me*₃SiCH₂-), δ 4.13 (s, -SiMe₃).

Preparation of [(Me₃SiCH₂)₂AlP(SiMe₃)₂]₂ (8). The procedure used was identical to that described for 6. with (Me₃-SiCH₂)₂AlBr (0.281 g; 1.00 mmol) and LiP(SiMe₃)₂·0.6THF (0.227 g; 1.00 mmol). [(Me₃SiCH₂)₂AlP(SiMe₃)₂]₂ (8) was isolated (0.266 g, 70% yield). Mp: 190-198 °C. Anal. Calcd (found) for C₂₈H₈₀Al₂P₂Si₈: C, 44.39 (44.19); H, 10.64 (10.79). ¹H NMR: δ -0.18 (bs, 8H, Me₃Si*CH*₂-), δ 0.35 (s, 36H, *Me*₃-SiCH₂-), δ 0.48 [t, 36H, -SiMe₃ ($J_{P-H} = 2.4 \text{ Hz}$)]. ¹³C{¹H} NMR: δ 2.48 (bs, Me₃Si*CH*₂-), δ 4.11 (s, *Me*₃SiCH₂-), δ 5.28 [t, $-SiMe_3 (J_{P-C} = 4.1 \text{ Hz})$]. ³¹P{¹H} NMR: δ -234.97 (s).

Preparation of [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (9). The procedure used was identical to that described for 6, with (Me₃-SiCH₂)₂AlBr (0.281 g; 1.00 mmol) and LiAs(SiMe₃)₂·0.6THF (0.270 g; 1.00 mmol). [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (9) was isolated (0.326 g, 77% yield). Mp: 201-212 °C (decomposed to a yellow liquid). Anal. Calcd (found) for $C_{28}H_{80}Al_2As_2Si_8$: C, 39.78 (39.77); H, 9.54 (9.79). ¹H NMR: δ –0.13 (s, 8H, Me₃-Si*CH*₂-), δ 0.35 (s, 36H, *Me*₃SiCH₂-), δ 0.51 (s, 36H, -SiMe₃). ¹³C{¹H} NMR: δ 2.89 (s, Me₃Si*CH*₂-), δ 3.39 (s, Me₃SiCH₂-), δ 5.19 (s, -SiMe₃).

Preparation of (Me₃SiCH₂)AlBr₂ (10). (Me₃SiCH₂)₃Al (1.00 g; 3.5 mmol) in 30 mL of hexane was added to a 250 mL

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Table 1. Crystallographic Data for (Me₃SiCH₂)₃Al·As(SiMe₃)₃ (2), (Me₃CCH₂)₃Al·P(SiMe₃)₃ (3), (Me₃CCH₂)₃Al·As(SiMe₃)₃ (4), (Me₃SiCH₂)₂(Br)Al·P(SiMe₃)₃ (5), [(Me₃SiCH₂)(Br)AlP(SiMe₃)₂]₂ (6), $[(Me_3SiCH_2)(Br)AlAs(SiMe_3)_2]_2$ (7), and $[(Me_3SiCH_2)_2AlAs(SiMe_3)_2]_2$ (9)

	2	3	4	5	6	7	9
formula	C21H60Al-	C24H60Al-	C24H60Al-	C17H49Al-	C ₂₀ H ₅₈ Al ₂ -	C ₂₀ H ₅₈ Al ₂ -	C28H80Al2-
	AsSi ₆	PSi_3	AsSi ₃	BrPSi ₅	$Br_2P_2Si_6$	As ₂ Br ₂ Si ₆	As ₂ Si ₈
fw	583.11	490.94	534.89	531.87	742.92	830.82	845.44
space group	$P3_1$	P3	P3	$P2_1/c$	$P2_1/c$	$P2_1/c$	Pbcn
<i>a</i> , Å	16.1093(25)	16.1189(12)	16.182(2)	12.847(1)	9.791(1)	9.850(1)	12.852(3)
<i>b</i> , Å				12.671(2)	19.392(3)	16.627(3)	21.095(2)
<i>c</i> , Å	12.0895(12)	11.285(2)	11.415(1)	20.573(3)	11.415(1)	11.452(1)	18.580(1)
β , deg				103.07(1)	111.782(9)	112.057(9)	
V, Å ³	2717.0(5)	2539.1(4)	2589.4(7)	3262.8(8)	2012.6(3)	2051.9(4)	5038(1)
Ζ	3	3	3	4	2	2	4
crystal color,	colorless	colorless	colorless	colorless	colorless	colorless	colorless
habit	block	block	block	block	block	block	block
$D(\text{calc}), \text{ g cm}^3$	1.069	0.963	1.029	1.083	1.226	1.345	1.115
μ (Mo K α), cm ⁻¹	11.6	2.22	11.23	15.22	23.26	38.04	15.68
temp, K	138	233(2)	233(2)	298(2)	298(2)	298(2)	251(2)
radiation			Mo	$K\alpha (\lambda = 0.710)$	73 Å)		. ,
$R(F), \%^{a}$	4.4	4.99	7.88	9.38	4.92	5.79	3.41
$R(wF^2), \%^a$	5.6	12.00	15.98	17.98	10.02	14.17	6.94

^{*a*} Quantity minimized = $R(wF^2) = \sum [w(F_0^2 - F_c^2)^2]/\sum [(wF_0^2)^2]^{1/2}; R = \sum \Delta / \sum (F_0), \Delta = |(F_0 - F_c)|.$

flask equipped with a stir bar and Teflon valve. AlBr₃ (1.80 g; 7.00 mmol) in 50 mL of hexane was added to the clear colorless solution, and stirring was continued at room temperature for 48 h. The solvent was removed in vacuo, and 10 was isolated as a clear, colorless liquid (1.60 g, 93% yield). ¹H NMR: δ -0.29 (s, 2H, Me₃Si*CH*₂-), δ 0.09 (s, 9H, Me₃Si-CH₂-). ¹³C{¹H} NMR: δ 1.75 (s, *Me*₃SiCH₂-).

¹H NMR Equilibration of 6 and 7. In a drybox, 6 (9.8 mg, 0.03 mmol) and 7 (11.0 mg, 0.03 mmol) were each dissolved separately in 0.37 mL of toluene-d₈. The two solutions were then added to the same NMR tube via pipet, and the tube was flame-sealed. An initial spectrum was taken, after which the sealed tube was placed in an oil bath at 70 °C. Spectra were recorded every 24 h for a period of 7 d. ¹H NMR (initial): δ -0.09 (bs, 4H, Me₃Si*CH*₂-, **6**), δ -0.03 (s, 4H, Me₃Si*CH*₂-, **7**), δ 0.33 (s, 36H, *Me*₃SiCH₂-, **6** and **7**), δ 0.50 [t, 36H, $-SiMe_3$ (J_{P-H} = 2.6 Hz), 6], δ 0.52 (s, 36H, -SiMe₃, 7). ³¹P{¹H} NMR (initial): δ -214.20 (s, 6). ¹H NMR (final): $\delta - 0.09$ (bs, Me₃Si*CH*₂-, **6**), $\delta - 0.07$ (bs), $\delta - 0.03$ (s, Me₃Si*CH*₂-, **7**), δ 0.33 (s, *Me*₃SiCH₂-, **6** and **7**), δ 0.49 (d, *J*_{P-H} = 5.2 Hz), δ 0.50 [t, -SiMe_3 (J_{\rm P-H} = 2.6 Hz), 6], δ 0.52 (s, -SiMe₃, 7), δ 0.53 (s). ³¹P{¹H} NMR (final): δ -214.23 (s, 6), δ -209.73 (s).

¹H NMR Equilibration of 8 and 9. The procedure used was identical to that described for 6 and 7. ¹H NMR (initial): δ –0.20 (bs, 8H, Me₃Si CH₂–, 8), δ –0.15 (s, 8H, Me₃Si CH₂–, 9), δ 0.34 (s, 72H, *Me*₃SiCH₂-, 8 and 9), δ 0.48 [t, 36H, -SiMe₃ $(J_{P-H} = 2.4 \text{ Hz}), 8$], $\delta 0.52$ (s, 36H, -SiMe₃, 9). ³¹P{¹H} NMR (initial): δ -234.97 (s). ¹H NMR (final): δ -0.15 (s, Me₃-Si*CH*₂-, **9**), δ 0.23 (d, J_{P-H} = 4.4 Hz), δ 0.34 (s, *Me*₃SiCH₂-, **8** and 9), δ 0.48 (d, J_{P-H} = 4.8 Hz), δ 0.48 [t, -SiMe₃ (J_{P-H} = 2.4 Hz), 8], δ 0.52 (s, -SiMe₃, 9). ³¹P{¹H} NMR (final): δ -234.18 (s), δ -230.19 (s), δ -226.25 (s).

High-Temperature ¹H NMR Study of 6. In a drybox, a NMR sample was prepared by dissolving a small amount of the crystalline solid (approximately 20.0 mg) in 0.75 mL of toluene- d_8 and adding the solution to the NMR tube via pipet. The tube was then flame-sealed. 1H NMR spectra were recorded at 25, 40, 60, 80, and 95 °C, allowing 5 min for equilibration at each temperature. The sample was then cooled, and spectra were recorded at 60 and 25 °C. ¹H NMR (95 °C): $\delta - 0.13$ (bs, 4H, Me₃Si*CH*₂-), $\delta 0.28$ (s, 18H, *Me*₃-SiCH₂-), δ 0.50 [t, 36H, -SiMe₃ ($J_{P-H} = 4.0$ Hz)].

High-Temperature ¹H NMR Study of 7. The procedure used was similar to that described for **6**. ¹H NMR (90 °C): δ -0.07 (s, 4H, Me₃Si*CH*₂-), δ 0.28 (s, 18H, *Me*₃SiCH₂-), δ 0.53 (s, 36H, -SiMe₃).

X-ray Structural Solution and Refinement. Crystallographic data are summarized in Table 1, while Table 2 lists selected bond lengths and bond angles. The structural analyses were performed as follows:

Compound 2. A single crystal of 2 was mounted on a glass fiber with a viscous oil under a stream of cold dinitrogen. X-ray intensity data were recorded at -135 °C on a Rigaku AFC6/S diffractometer utilizing graphite-monochromated Mo Ka radiation ($\lambda = 0.710$ 73 Å), and the structure was solved by direct methods. Full-matrix least-squares refinement with weights based upon counting-statistics was performed. Hydrogen atoms were incorporated at their calculated positions using a riding model in the later iterations of refinement which converged at R = 0.044 ($R_w = 0.056$). A final difference Fourier synthesis revealed no unusual features. Crystallographic calculations were performed using the NRCVAX¹³ suite of structure determination programs. For all structure-factor calculations, neutral atom scattering factors and their anomalous dispersion corrections were taken from ref 14. An ORTEP¹⁵ diagram showing the solid-state confirmation and atom numbering scheme for **2** is shown in Figure 1.

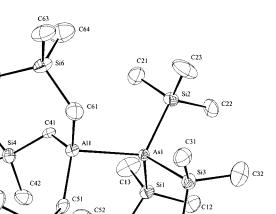
Compounds 3-7 and 9. Suitable crystals were selected and mounted in nitrogen-flushed glass capillaries and flamesealed. The unit-cell parameters were obtained by the leastsquares refinement of the angular settings of 24 reflections $(20^{\circ} \le 2\theta \le 24^{\circ})$. The systematic absences in the diffraction data are consistent with the trigonal space groups P3 and P3 for **3** and **4**, uniquely consistent for the space group $P2_1/c$ for 5-7, and uniquely consistent for the space group *Pbcn* for 9. Solution in both the centrosymmetric and the chiral option were pursued for **3** and **4**, but only solution in the chiral space group, P3, afforded chemically reasonable and computationally stable results of refinement. The structures were solved using direct methods, completed by subsequent difference Fourier syntheses, and refined by full-matrix least-squares procedures. Semiempirical ellipsoid absorption corrections were not necessary because there was less than 10% intensity variation in the ψ -scan data. There are three independent, but chemically equivalent, molecules in the asymmetric unit for 3 and 4. The molecule in 6 and 7 lies on a crystallographic inversion center, and the molecule in 9 is located on a 2-fold axis. The absolute

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(14) International Tables for X-ray Crystallography; The Kynoch Press: Birmingham, England, 1974; Vol. IV.
(15) Johnson, C. K. ORTEP-A Fortran Thermal Ellipisoid Plot

Program; Technical Report ORNL-5138; Oak Ridge National Laboratory: Oak Ridge, TN, 1976.

Table 2.Selected Bond Lengths (Å) and Angles(deg) for 2-7 and 9, with Estimated StandardDeviations in Parentheses

Al(1)-As(1) Al(1)-C(41) Al(1)-C(51) Al(1)-C(61)	Bond Len 2.671(3) 1.985(9) 2.009(10) 1.989(10)	gths for 2 As(1)-Si(1) As(1)-Si(2) As(1)-Si(3)	2.377(3) 2.367(3) 2.371(3)
$\begin{array}{l} Al(1)-As(1)-Si(1)\\ Al(1)-As(1)-Si(2)\\ Al(1)-As(1)-Si(3)\\ Si(1)-As(1)-Si(2)\\ Si(1)-As(1)-Si(2)\\ Si(2)-As(1)-Si(3)\\ Si(2)-As(1)-Si(3)\\ \end{array}$	Bond Ang 111.15(10) 116.15(10) 114.17(10) 104.34(11) 105.57(10) 104.45(10)	gles for 2 As(1)-Al(1)-C(41 As(1)-Al(1)-C(51 As(1)-Al(1)-C(61 C(41)-Al(1)-C(51 C(41)-Al(1)-C(61 C(51)-Al(1)-C(61)	 99.2(3) 102.5(3) 115.7(4) 116.2(4)
Al-P Al-C(4)	Bond Leng 2.681(4) 1.996(4)	gths for 3 P–Si	2.278(2)
		gles for 3 P–Al–C(4) C(4)–Al–C(4A)	95.3(2) 119.17(5)
Al-As Al-C(4)	Bond Len 2.72(2) 1.97(2)	gths for 4 As–Si	2.363(7)
Al–As–Si Si–As–SiA	Bond Ang 114.3(2) 104.3(3)	As-Al-C(4) C(4)-Al-C(4A)	97.0(9) 118.5(3)
Al-P Al-Br Al-C(1) Al-C(5)	Bond Len 2.498(7) 2.351(5) 1.97(2) 1.96(2)	gths for 5 P-Si(3) P-Si(4) P-Si(5)	2.271(6) 2.306(6) 2.286(7)
$\begin{array}{l} Al - P - Si(3) \\ Al - P - Si(4) \\ Al - P - Si(5) \\ Si(3) - P - Si(4) \\ Si(3) - P - Si(5) \\ Si(4) - P - Si(5) \end{array}$	Bond Ang 110.5(2) 113.2(3) 111.7(2) 107.4(2) 107.7(3) 106.1(3)	gles for 5 P-Al-Br P-Al-C(1) P-Al-C(5) Br-Al-C(1) Br-Al-C(5) C(1)-Al-C(5)	100.7(2) 104.4(6) 107.0(5) 109.2(5) 113.4(6) 119.9(7)
Al(1)-P(1) Al(1)-Br(1) P(1)-Si(1)	Bond Len 2.436(2) 2.312(2) 2.276(3)	gths for 6 Al(1)-P(1A) Al(1)-C(7) P(1)-Si(2)	2.435(3) 1.941(7) 2.273(3)
Al(1)-P(1)-Al(1A)Br(1)-Al(1)-P(1)Br(1)-Al(1)-P(1A)Br(1)-Al(1)-C(7)Si(1)-P(1)-Al(1)Si(1)-P(1)-Al(1A)	113.5(2) 113.18(10) 114.79(10) Bond Len	$\begin{array}{l} P(1)-Al(1)-P(1A)\\ C(7)-Al(1)-P(1)\\ C(7)-Al(1)-P(1)\\ Si(1)-P(1)-Si(2)\\ Si(2)-P(1)-Al(1)\\ Si(2)-P(1)-Al(1A)\\ gths for 7 \end{array}$	
Al–As Al–Br As–Si(2)	2.505(3) 2.316(3) 2.364(3)	Al–AsA Al–C(4) As–Si(3)	2.515(3) 1.955(10) 2.362(3)
Al-As-AlA Br-Al-As Br-Al-AsA Br-Al-C(4) Si(2)-As-Al Si(2)-As-AlA	Bond Ang 90.15(9) 105.52(11) 107.99(12) 114.2(3) 119.65(10) 111.45(10)	gles for 7 As-Al-AsA C(4)-Al-As C(4)-Al-AsA Si(2)-As-Si(3) Si(3)-As-Al Si(3)-As-AlA	89.85(9) 122.3(3) 113.9(3) 107.23(11) 113.05(10) 114.85(10)
Al(1)-As Al(1)-C(4) As-Si(3)	Bond Len 2.567(2) 1.962(4) 2.358(2)	Al(2)-As Al(2)-C(8) As-Si(4)	2.560(2) 1.965(4) 2.357(2)
$\begin{array}{l} Al(1)-As-Al(2)\\ As-Al(2)-AsA\\ C(4)-Al(1)-As\\ C(8)-Al(2)-C(8A)\\ C(8)-Al(2)-C(8A)\\ C(8)-Al(2)-AsA\\ Si(3)-As-Al(1)\\ Si(4)-As-Al(1) \end{array}$	Bond Ang 92.85(4) 87.31(6) 115.7(2) 122.2(3) 107.29(14) 111.40(5) 121.42(5)	gles for 9 As-Al(1)-AsA C(4)-Al(1)-C(4A) C(4)-Al(1)-AsA C(8)-Al(2)-As Si(3)-As-Si(4) Si(3)-As-Al(2) Si(4)-As-Al(2)	$\begin{array}{c} 86.99(7)\\ 122.1(3)\\ 105.54(13)\\ 113.7(2)\\ 104.04(6)\\ 116.03(5)\\ 111.61(5)\\ \end{array}$



CH

 \mathcal{V}_{c33}

C62

C53

Figure 1. ORTEP diagram (30% probability ellipsoids), showing the solid-state structure and atom-numbering scheme for $(Me_3SiCH_2)_3Al\cdot As(SiMe_3)_3$ (2). Hydrogen atoms are omitted for clarity.

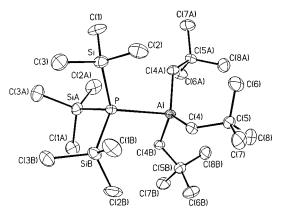


Figure 2. ORTEP diagram of (Me₃CCH₂)₃Al·P(SiMe₃)₃ (**3**), showing the atom-labeling scheme. Only one of the three independent, but chemically equivalent, molecules are shown. Thermal ellipsoids are at 30% probability, and hydrogen atoms are omitted for clarity.

configuration of **3** was determined (Flack = 0.2(2)), and **4** was refined as a 70/30 racemic twin. All non-hydrogen atoms were refined with anisotropic displacement coefficients, except for the carbon atoms of **4** and carbon atoms on the trimethysilyl groups of **5** which were refined isotropically to conserve data. Hydrogen atoms were treated as idealized contributions. Structures **3** and **4** are isomorphous, as are structures **6** and **7**. ORTEP diagrams are found in Figures 2–7.

All software and sources of the scattering factors are contained in the SHELXTL (version 5.3) program library (G. Sheldrick, Siemens XRD, Madison, WI).

Results and Discussion

The room-temperature, 1:1 reactions of $(Me_3SiCH_2)_3$ -Al with P(SiMe_3)_3 and As(SiMe_3)_3 yield the expected Lewis acid—base adducts $(Me_3SiCH_2)_3Al\cdotP(SiMe_3)_3$ (1) and $(Me_3SiCH_2)_3Al\cdotAs(SiMe_3)_3$ (2), respectively. These adducts have been characterized through multinuclear NMR, partial elemental analysis, and, in the case of 2, single-crystal X-ray analysis. Repeated attempts to

1

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9

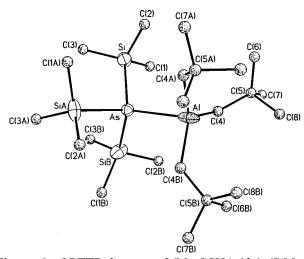


Figure 3. ORTEP diagram of $(Me_3CCH_2)_3Al\cdot As(SiMe_3)_3$ (4), showing the atom-labeling scheme. Only one of the three independent, but chemically equivalent, molecules are shown. Thermal ellipsoids are at 30% probability, and hydrogen atoms are omitted for clarity.

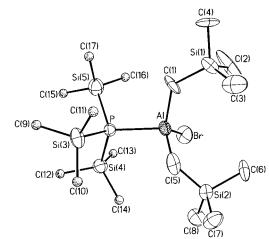


Figure 4. ORTEP diagram of (Me₃SiCH₂)₂(Br)Al·P(SiMe₃)₃ (5), showing the atom-labeling scheme. Thermal ellipsoids are at 30% probability, and hydrogen atoms are omitted for clarity.

recrystallize 1 failed to yield X-ray-quality crystals. These reactions are analogous to those used previously to form (Me₃SiCH₂)₃M·P(SiMe₃)₃ and (Me₃SiCH₂)₃M·As- $(SiMe_3)_3$, where $M = Ga^{6e}$ or $In.^{16}$ The (trimethylsilyl)methyl- groups on the aluminum and the trimethylsilyl- groups on the arsenic of 2 adopt a staggered conformation to one another, and both the aluminum and arsenic reside in distorted tetrahedral environments. The Al–As bond length of 2.671(3) Å is well within the expected range and compares favorably with the average Al-As distance of 2.60 Å reported for the adduct Ph₃Al·As(SiMe₃)₃.³ The slightly longer bond length in 2 can be attributed to the greater steric bulk of the alkyl- groups around the aluminum when compared to the phenyl- groups. These phenylgroups are also electron withdrawing, serving to increase the Lewis acidity of the aluminum and decrease the bond length. The average As-Al-C bond angle of 101.0° in **2** is also smaller than the corresponding average angle of 104.5° seen in Ph₃Al·As(SiMe₃)₃.

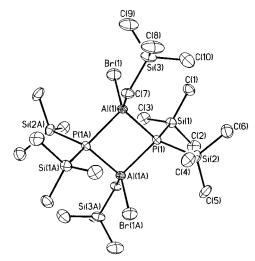


Figure 5. ORTEP diagram of [(Me₃SiCH₂)(Br)AlP(SiMe₃)₂]₂ (**6**), showing the atom-labeling scheme. Thermal ellipsoids are at 30% probability, and hydrogen atoms are omitted for clarity.

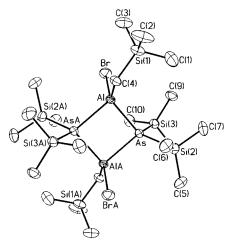


Figure 6. ORTEP diagram of $[(Me_3SiCH_2)(Br)AlAs-(SiMe_3)_2]_2$ (7), showing the atom-labeling scheme. Thermal ellipsoids are at 30% probability, and hydrogen atoms are omitted for clarity.

Similarly, the independent 1:1 reactions of (Me₃-CCH₂)₃Al with P(SiMe₃)₃ and As(SiMe₃)₃ at room temperature in hexane solution result in a high yield of the Lewis acid-base adducts (Me₃CCH₂)₃Al·P(SiMe₃)₃ (3) and (Me₃CCH₂)₃Al·As(SiMe₃)₃ (4). Again, the (trimethylsilyl)methyl- and trimethylsilyl- groups adopt a staggered conformation with respect to one another, and the aluminum and pnicogen atoms reside in distorted tetrahedral environments. The average Al-P bond length of 2.67 Å found in **3** is longer than the analogous Al-P distance of 2.52 Å found in Ph₃Al·P(SiMe₃)₃,³ again due to the decreased steric bulk and electron withdrawing nature of the phenyl-group. The average Al–As bond length of 2.72 Å found in 4 is comparable to the Al–As bond length of 2.671(3) Å in 2, due to the similarity of the ligands attached to the aluminum atoms.

The 1:1 mixture of $(Me_3SiCH_2)_2AlBr$ and $P(SiMe_3)_3$ fails to undergo intermolecular dehalosilylation at room temperature and instead affords the Lewis acid–base adduct $(Me_3SiCH_2)_2(Br)Al\cdot P(SiMe_3)_3$ (5). This result is not surprising, and the failure of aluminum to partici-

⁽¹⁶⁾ Wells, R. L.; McPhail, A. T.; Jones, L. J.; Self, M. F.; Butcher, R. J. Organometallics **1992**, *11*, 2694.

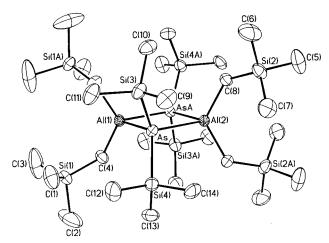


Figure 7. ORTEP diagram of [(Me₃SiCH₂)₂AlAs(SiMe₃)₂]₂ (**9**), showing the atom-labeling scheme. Thermal ellipsoids are at 30% probability, and hydrogen atoms are omitted for clarity.

pate in dehalosilylation reactions has been well documented,^{3,17} especially in the case of aluminum-phosphorus linkages. The isolation of **5** shows that the trend holds for this system as well. The Al-P bond length of 2.498(7) Å is very close to the analogous length in a similar structure, Ph₂ClAl·P(SiMe₃)₃,³ found to be 2.467-(2) Å. Another interesting comparison between these structures is the P-Al-halogen bond angle of 100.7-(2)° in **5** and 102.1(1)° in Ph₂ClAl·P(SiMe₃)₃, where the increased size of the bromine atom combined with the increased steric bulk of the (trimethylsilyl)methyl–groups appears to have a small effect. The aluminum and phosphorus atoms in **5**, as expected, reside in distorted tetrahedral environments with the attached groups adopting a staggered conformation.

The 1:1 salt-elimination reactions between (Me₃-SiCH₂)AlBr₂ (10) and LiP(SiMe₃)₂ and LiAs(SiMe₃)₂ yield the anticipated dimers [(Me₃SiCH₂)(Br)AlP(Si- $Me_{3}_{2}_{2}_{2}$ (6) and $[(Me_{3}SiCH_{2})(Br)AlAs(SiMe_{3})_{2}]_{2}$ (7), respectively. The synthesis of 10 was effected by comproportionation between (Me₃SiCH₂)₃Al and AlBr₃. Similarly, reaction of (Me₃SiCH₂)₂AlBr with LiP(SiMe₃)₂ and LiAs(SiMe₃)₂ yielded the dimers [(Me₃SiCH₂)₂AlP- $(SiMe_3)_2]_2$ (8) and $[(Me_3SiCH_2)_2AlAs(SiMe_3)_2]_2$ (9), respectively. Their structures were determined by singlecrystal X-ray diffraction, except for 8. The suggested dimer structure of 8 is based solely on the triplet present in the ¹H NMR spectrum, which appears as a result of virtual coupling of the trimethylsilyl- protons to the two phosphorus atoms in the central ring. Attempts to isolate X-ray-quality crystals of this compound were unsuccessful. The average Al-P bond length of 2.44 Å in 6 is very close to the average Al-P bond length of 2.46 Å found in the dimer [Et₂AlP(SiMe₃)₂]₂.⁴ The average endocyclic ring angles in 6 are 89.4° for Al-P-Al and 90.6° for P-Al-P, and the central Al-P-Al-P ring is planar as evidenced by the inversion center present in the molecule. The (trimethylsilyl)methylgroups and bromine atoms also adopt a trans conformation in relation to one another. In 7, the average Al-As bond length of 2.51 Å also compares well with the average length of 2.53 Å reported for the dimer [Et₂-

AlAs(SiMe₃)₂]₂.⁵ The exocyclic bromine atoms are again in a trans conformation, and the endocyclic ring angles are 90.15(9)° for Al–As–Al and 89.85(9)° for As–Al– As. Again, the inversion center present in the molecule demonstrates the planarity of this central ring. The average Al–As bond length of 2.57 Å and the average Al–As–Al and As–Al–As endocyclic ring angles of 92.9 and 87.2°, respectively, of **9** compare well with the analogous lengths and angles reported for **7** and the dimer [Et₂AlAs(SiMe₃)₂]₂ (vide supra).

In an attempt to study the solution behavior of these dimeric compounds, and judge the utility of equilibrating them to form a mixed-pnicogen type structure as in Et₂AlP(SiMe₃)₂Al(Et)₂As(SiMe₃)₂,¹⁸ two independent NMR tube equilibration reactions were attempted, the first between **6** and **7** and the second between **8** and **9**. Repeated scans of the samples at room temperature revealed no change in the peak multiplicities, positions, or integrations. However, heating the samples to 70 °C for 7 days resulted in a significant change in both samples. In the case of 6 and 7, the triplet assigned to the $-SiMe_3$ protons of **6** lost intensity, and a new doublet appeared in this same region at δ 0.49 ($J_{\rm P-H}$ = 5.2 Hz), superimposed on the triplet. Two new singlets also appeared in the ¹H spectra, at δ –0.07 and 0.53. In addition, a new peak was observed in the ${}^{31}P{}^{1}H$ NMR spectra, at δ –209.72. Presumably, these new peaks arise from and are consistent with the formation of the desired mixed-pnicogen structure. However, the compound seems to be in equilibrium with the starting dimers, since there was no noticeable change in the spectra after 4 days, and all three compounds still were present. In the equilibration of dimers 8 and 9, no mixed-pnicogen structure was observed on heating, but **8** decomposed. This is shown most clearly by the rapid reduction in intensity of the triplet assigned to the $-SiMe_3$ protons of **8** in comparison to the $-SiMe_3$ protons of 9. This triplet was replaced with a doublet centered at δ 0.48 (J_{P-H} = 4.8 Hz), apparently due to the decomposition product.

In the only recorded cases of internal dehalosilylation by aluminum-arsenic compounds, trimethylsilyl chloride elimination was induced by heating a sample of Cl₃-Al·As(SiMe₃)₃ in a cool flame¹⁹ or by heating Et₂(Cl)Al· As(SiMe₃)₃ at 87 °C in an NMR tube.⁵ Both a bromine atom and a trimethylsilyl- group are present in 6 and 7, allowing for the potential loss of trimethylsilyl bromide to form a cubane or rearrange to another novel structure. To explore this possibility, a high-temperature ¹H NMR study of **6** and **7** was undertaken. Since it was of interest to isolate an intermediate compound as opposed to the aluminum pnictide, these studies were done at the same temperature used to initiate elimination in $Et_2(Cl)Al \cdot As(SiMe_3)_3$ (vide supra). In both cases, no trimethylsilyl bromide elimination occurred. Both dimers maintained their integrity, as there was no change in the spectra up to 95 °C (for 6) or 90 °C (for **7**). In fact, the triplet in the spectra of **6** due to the trimethylsilyl- protons was still present, indicating the dimeric structure of this compound is maintained at the

⁽¹⁸⁾ Laske Cooke, J. A.; Wells, R. L.; White, P. S. Organometallics 1995, 14, 3562.

⁽¹⁹⁾ Wells, R. L.; Pitt, C. G.; McPhail, A. T.; Purdy, A. P.; Shafieezad, S.; Hallock, R. B. *Mater. Res. Soc. Symp. Proc.* **1989**, *131*, 45.

higher temperature. A notable difference between **6** and **7** and $Et_2(Cl)Al\cdot As(SiMe_3)_3$ is that, in the present study, the attempted intramolecular dehalosilylation involves loss of the "second" trimethylsilyl– group from the phosphorus or arsenic atom. While $P(SiMe_3)_3$ and $As(SiMe_3)_3$ readily participate in room temperature dehalosilylation reactions, it has been seen in our laboratory that loss of a second or third trimethylsilyl– group is often difficult, requiring progressively higher temperatures.²⁰ Considering this, as well as the unwillingness

of aluminum to participate in dehalosilylation reactions in general, the stability of **6** and **7** at increased temperatures can be understood.

Acknowledgment. We wish to thank the Office of Naval Research and the ONR AASERT Program for their financial support of this work.

Supporting Information Available: Tables of X-ray parameters, bond distances, bond angles, anisotropic temperature factor parameters, and fractional coordinates and U values for 2-7 and 9 (42 pages). Ordering information is given on any current masthead page.

OM980097M

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